

Scanning Electron Microscopy, SEM

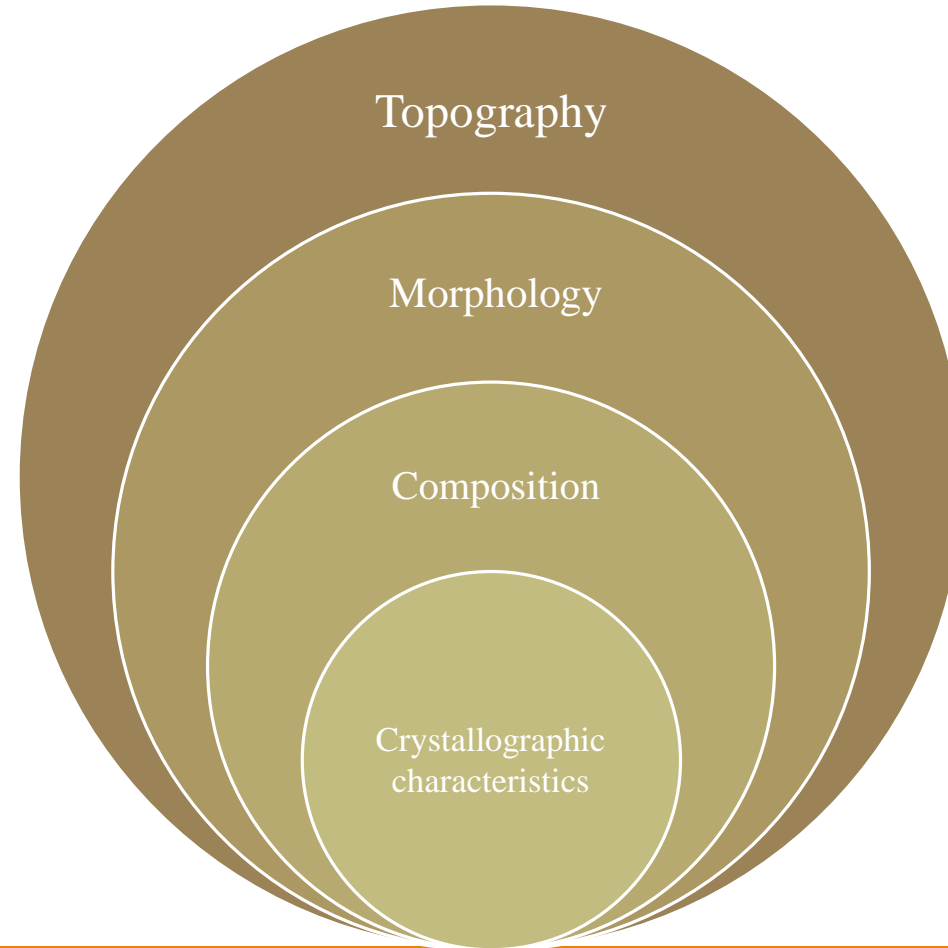
ERKKA KOSKENNIEMI, TRANG PHAM, 3.5.2023



Content

- Introduction to Scanning Electron Microscope
 - Purpose
 - How does SEM work
 - Challenges
 - Advantages/Disadvantages
 - Research examples

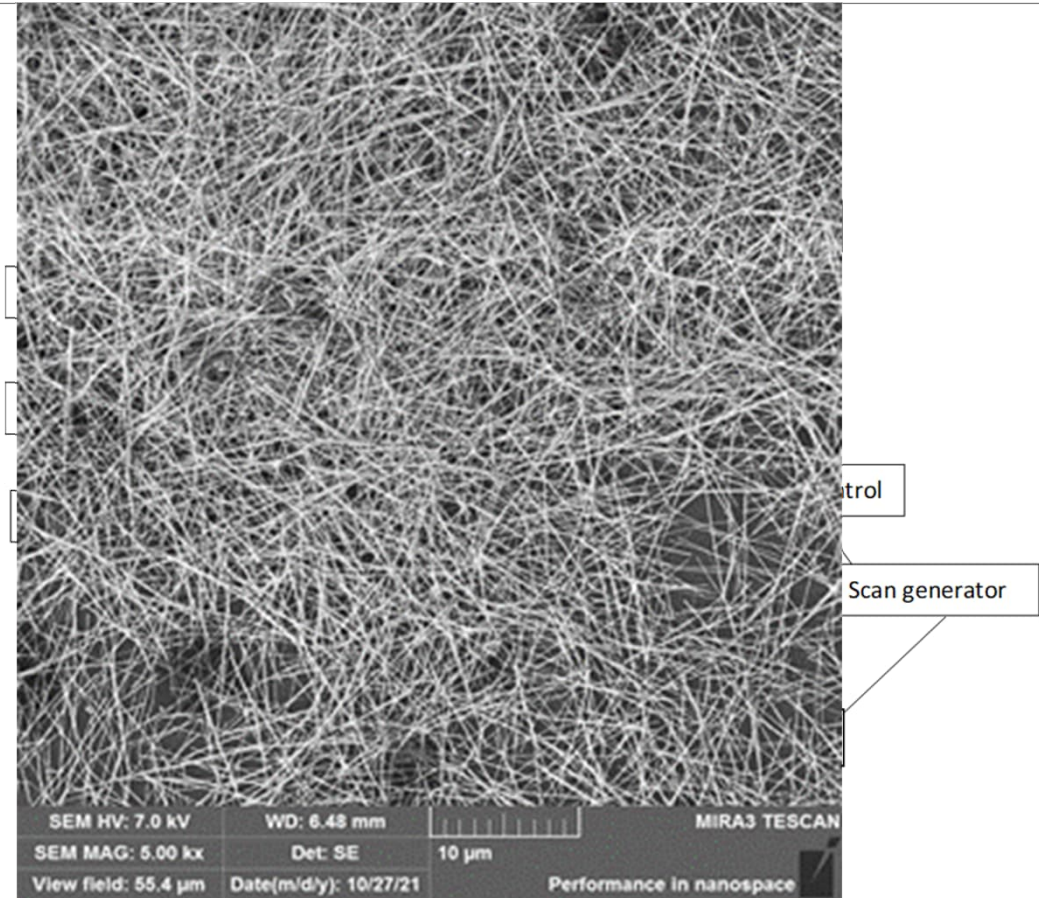
What is SEM used for?



SEM Instrumentation

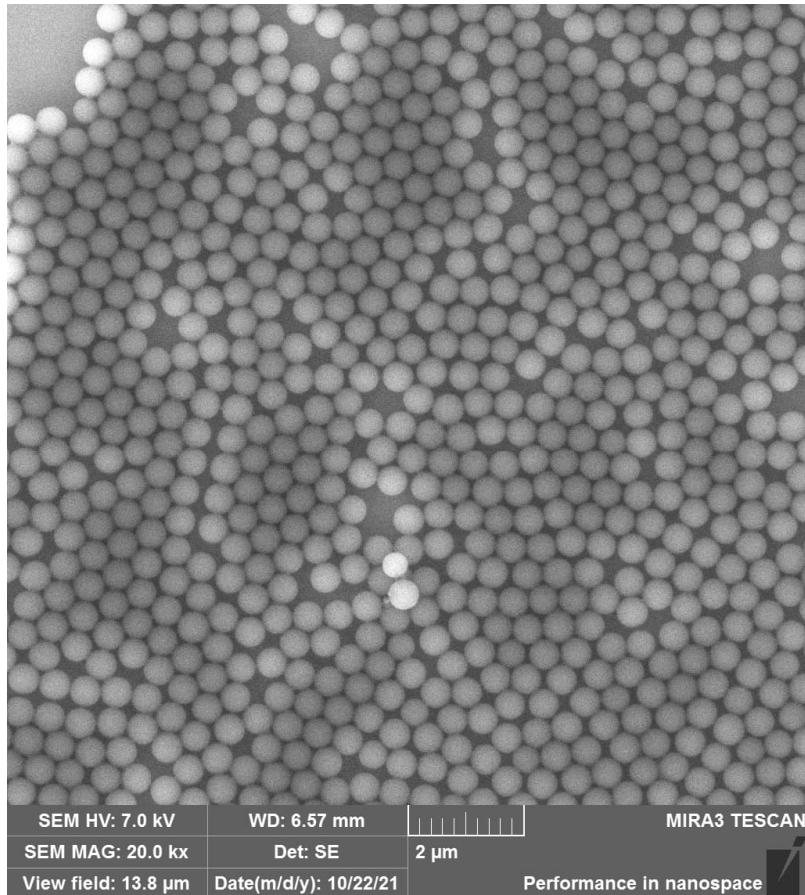
Consists of:

- Electron gun
- Electromagnetic coils (scan coils), objective lenses and condensers.
- Vacuum chamber
- Detector

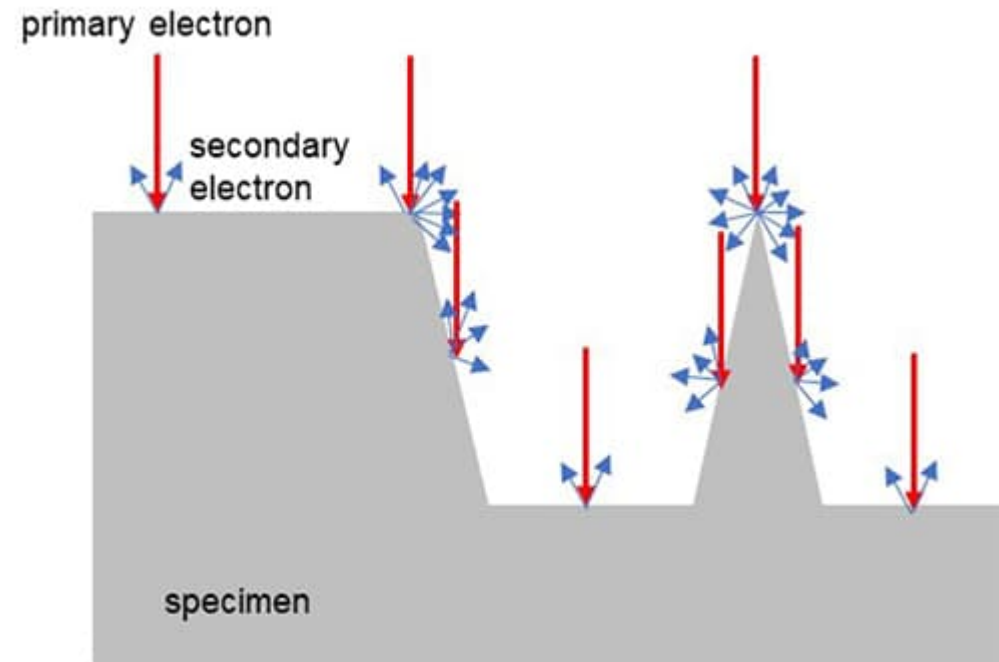


[1]

How does SEM work? Secondary electrons

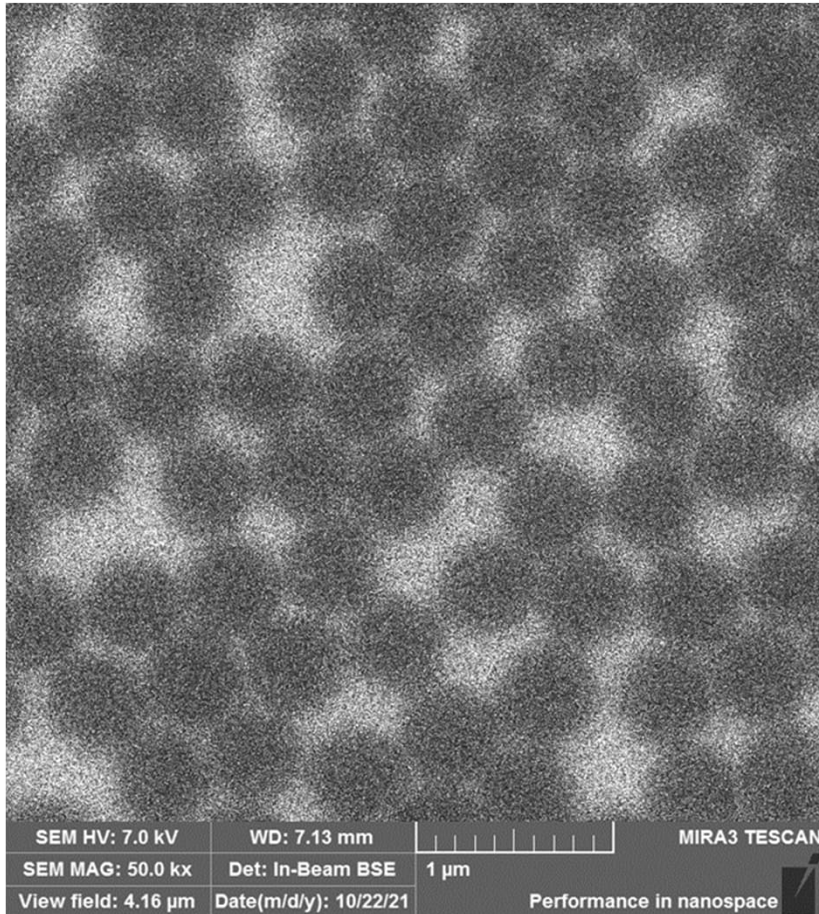


[1]

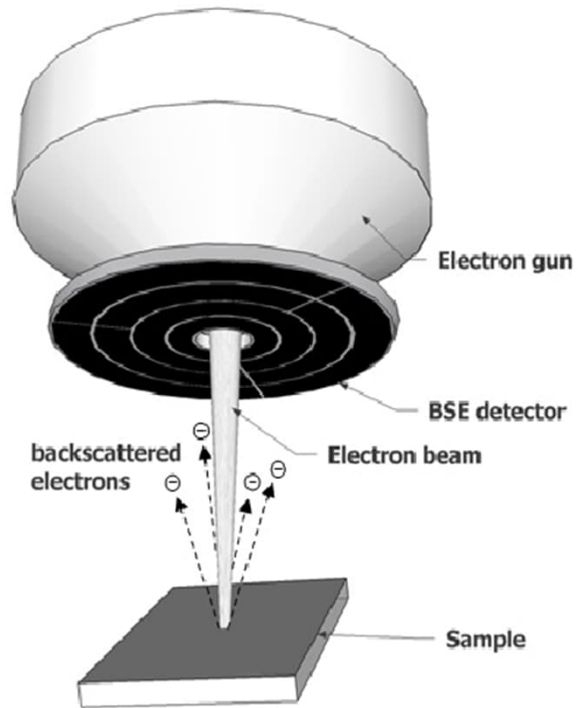


[2]

How does SEM work? Backscattered electrons



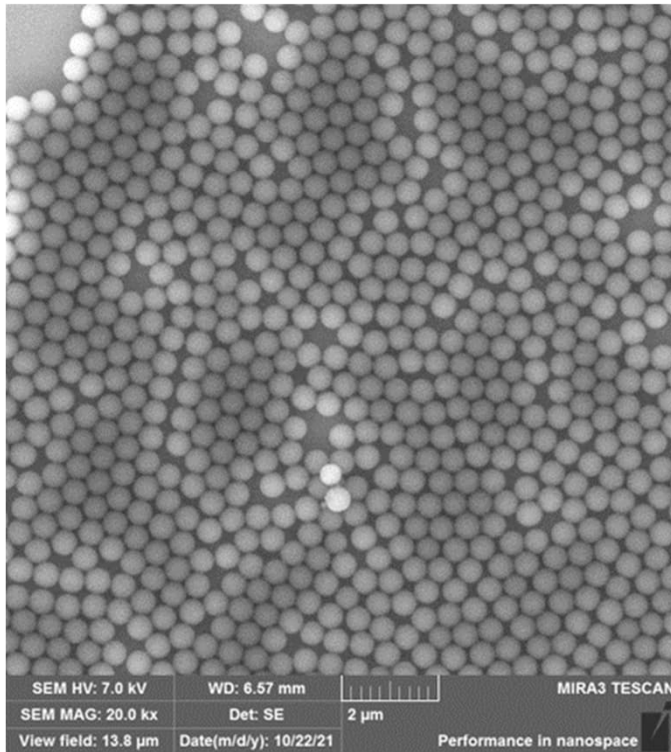
[1]



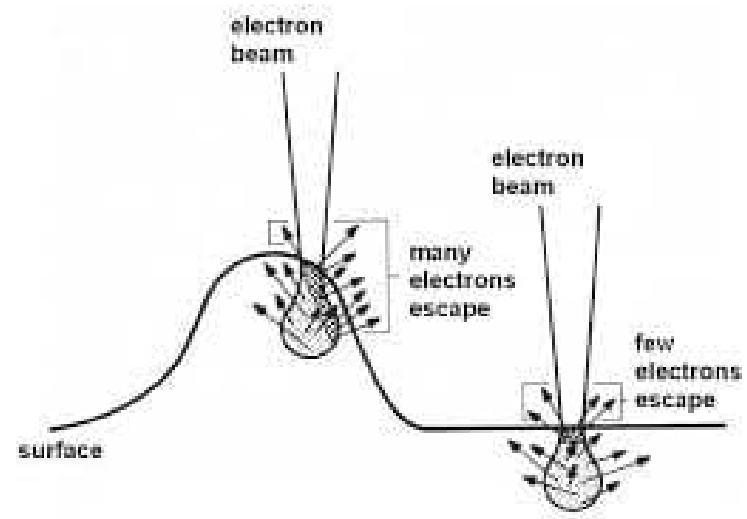
[4]

Also some X-rays

Difficulties: Edge effect



[1]



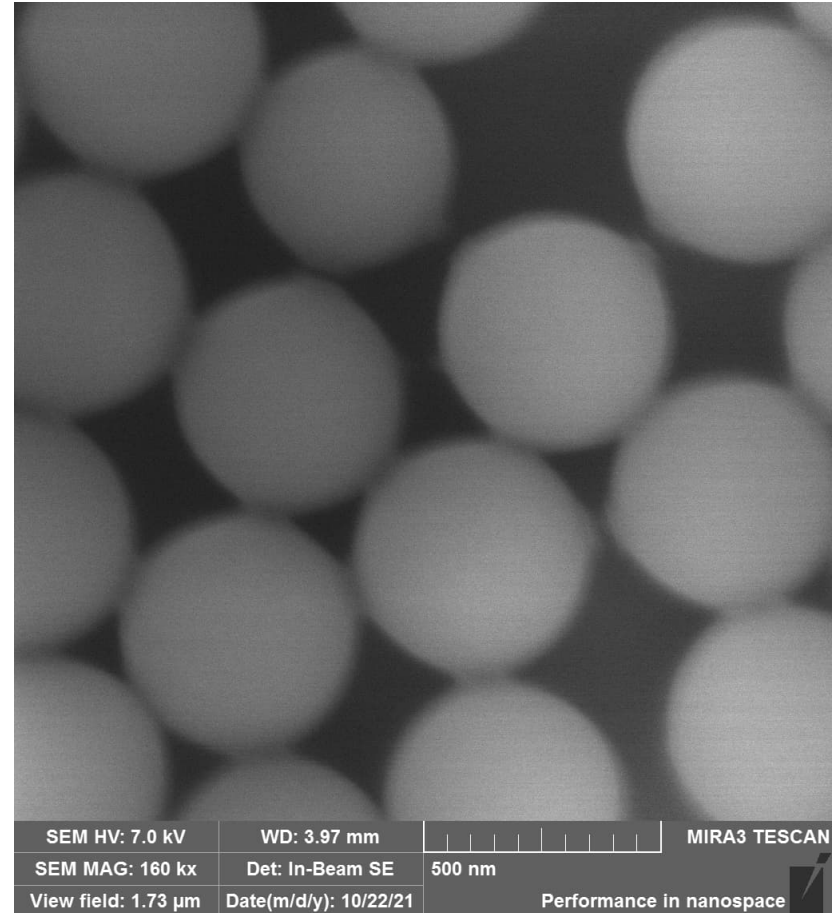
Edge effect [3]

Difficulties: Holes or hills?

Holes can look like hills

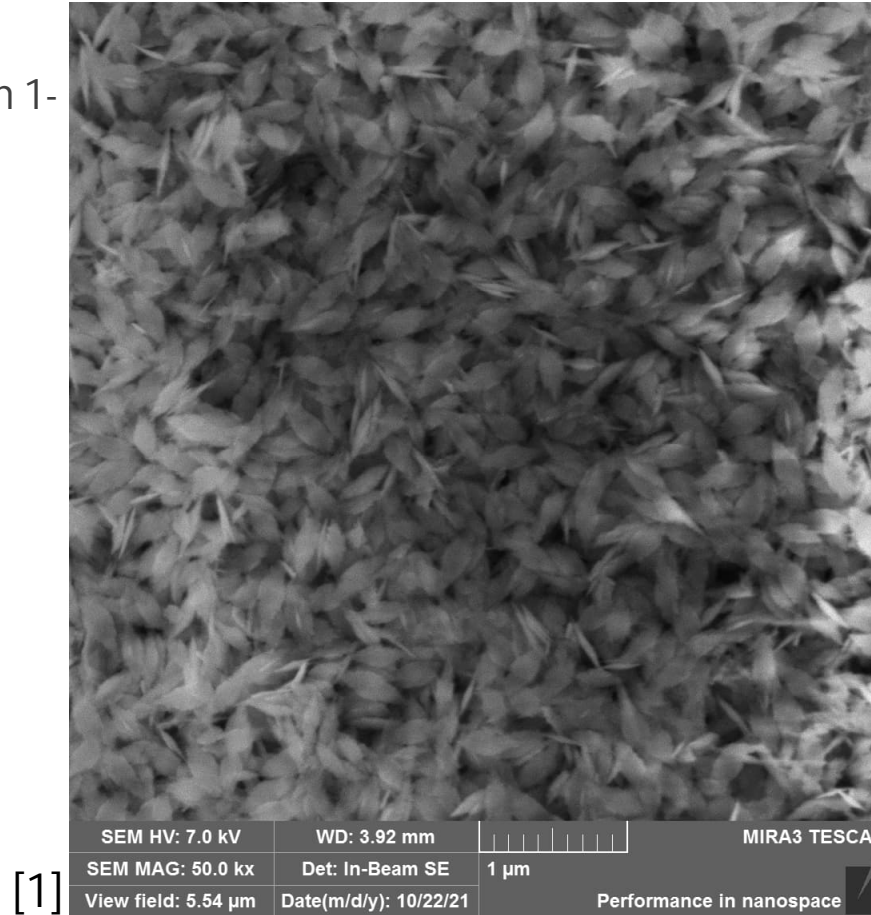
Hard to differentiate with naked eyes

Solution: Tilting



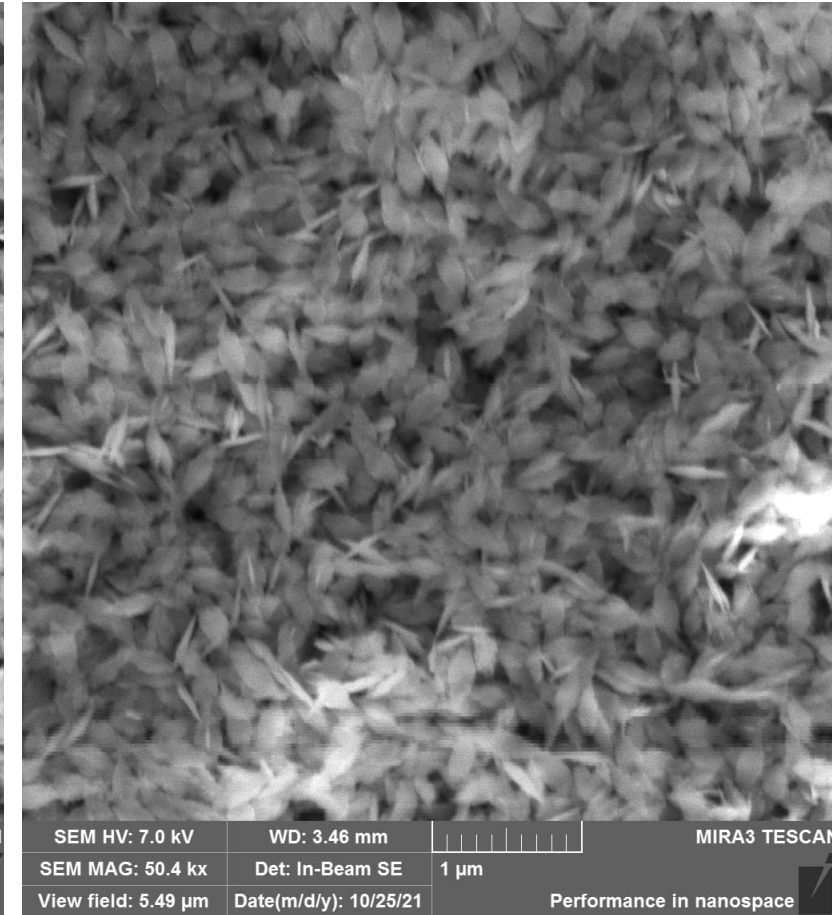
Difficulties:Settings

- Electron gun voltage
 - Nonconductive material is between 1-7 kV,
 - Semiconductive 7-12 kV
 - Metals as much as one wants to.
- Intensity and distance
- Non conductive (electron trap)



[1]

Copper oxide 1 [1]



Copper oxide 2

Data on the SEM image

SEM HV: Voltage used by Electron gun

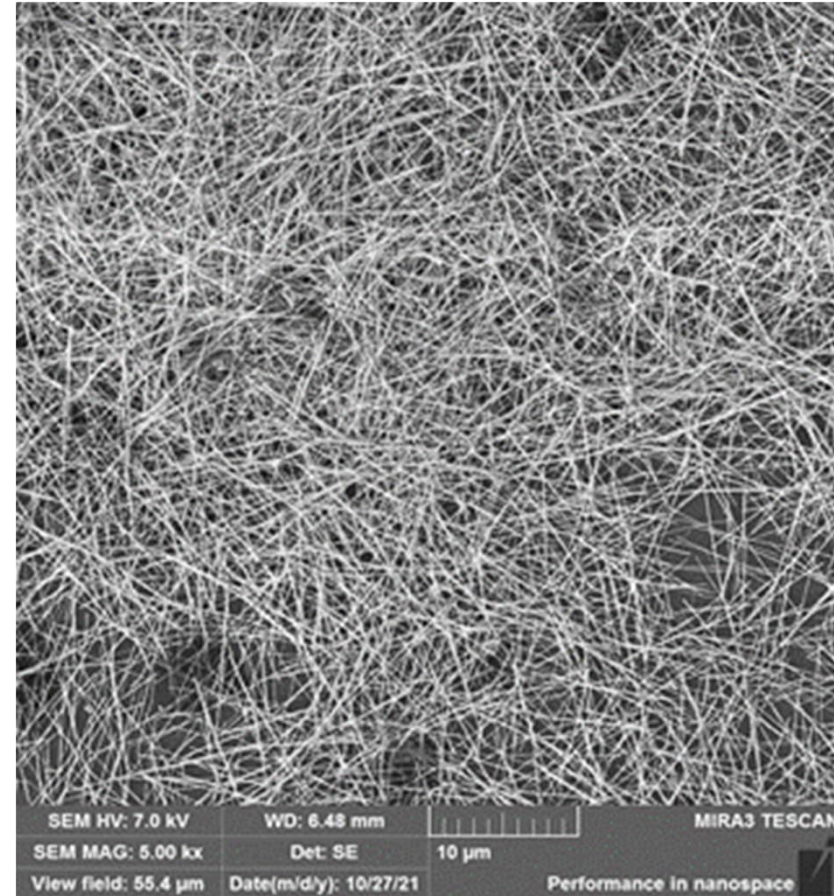
SEM MAG: Current Magnification

WD: Working distance, Distance between sample and electron gun

Det: Detector type. Either SE, BSE or In-beam SE/BSE

View field: Scale of the Sem picture shown. Length of the side of the image

Date (m/d/y): Date of the experiment



[1]

Advantages and disadvantages

Advantages

- Creates highly accurate 3D feed! (SE)
- Precision 10-1 micrometers!
- Elemental distinction (BSE)
- Elemental analysis also possible (X-Rays, EDS)
- Sample is not harmed*

Disadvantages

- Too much intensity can harm the sample
- Samples of poor electric conductivity require covering (electric tap)
- Biological samples require dehydration
- limited information under the surface

Research Examples

Simple and Efficient Route to Prepare Homogeneous Samples of $\text{Sr}_2\text{FeMoO}_6$ with a High Degree of Fe/Mo Order

Y. H. Huang, J. Lindén, H. Yamauchi, and M. Karppinen

View Author Information 

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Publication Date: September 24, 2004 

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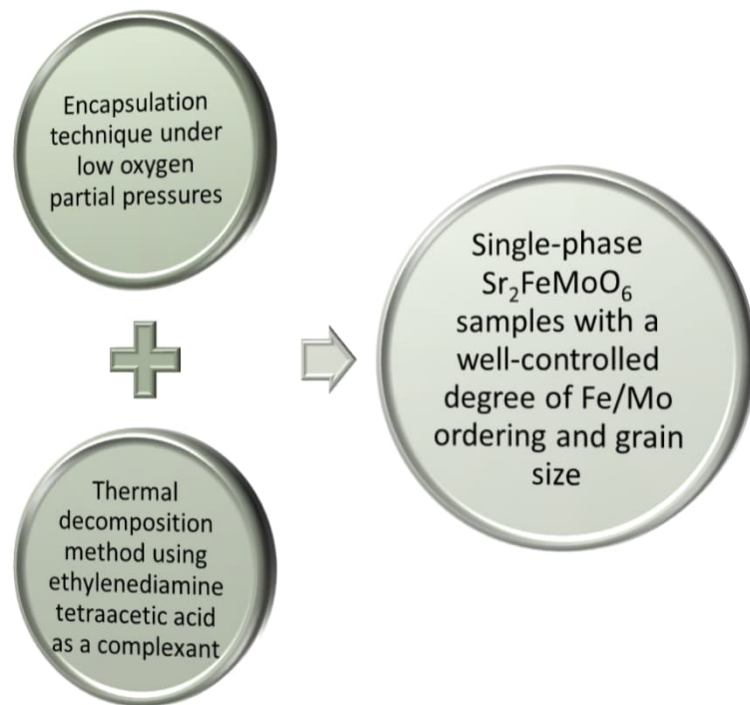
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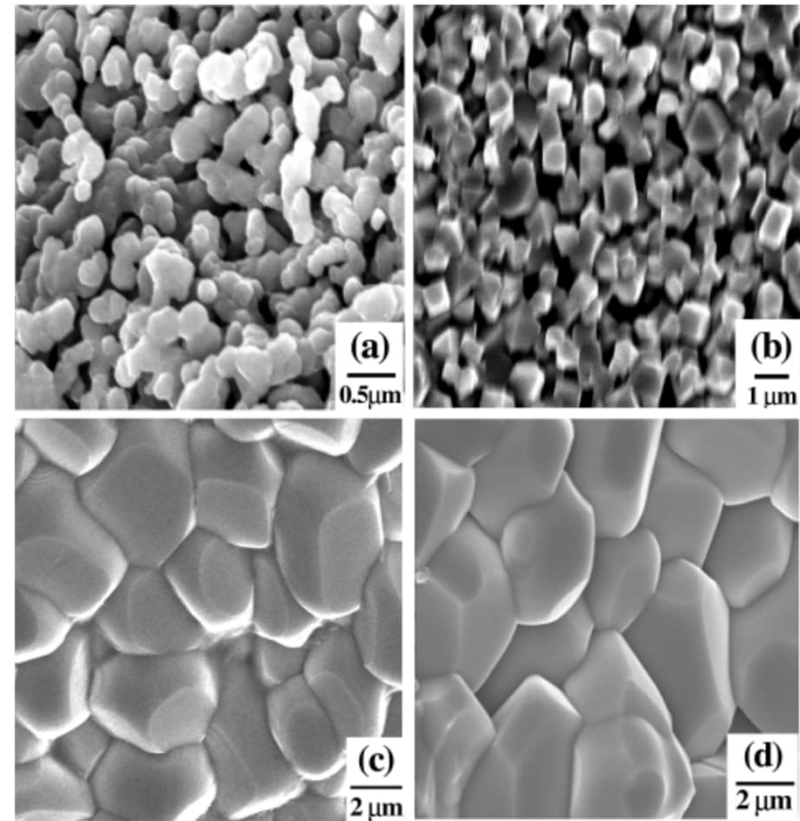


Characteristic methods used in the study:

- XRD: Crystal structure and composition → confirm the formation of the $\text{Sr}_2\text{FeMoO}_6$ phase, and analyze the degree of Fe/Mo order.
- SEM: analyze the morphology → particle size and shape of the samples.
- EDS: elemental analysis → confirm the presence of strontium, iron, and molybdenum.
- Vibrating sample magnetometry (VSM): magnetic properties → confirm the ferromagnetic properties.

SEM images for $\text{Sr}_2\text{FeMoO}_6$ samples obtained at different sintering temperatures.

- ❑ T = 900°C (24h) - round grains ($\sim 0.1 \mu\text{m}$), aggregation.
 - ❑ T = 1000°C (50 h) – cubic shape ($\sim 0.5 \mu\text{m}$).
 - ❑ T = 1150°C - polyhedral grains ($\sim 3 \mu\text{m}$).
- morphology looks highly homogeneous
- shape of the grains depends mainly on Ts
- the sintering of the grains/crystallization becomes enhanced as Ts increases.



SEM images for $\text{Sr}_2\text{FeMoO}_6$ samples under different conditions: (a) 900 °C for 24 h, (b) 1000 °C for 50 h, (c) 1150 °C for 50 h, and (d) 1150 °C for 100 h. [5]

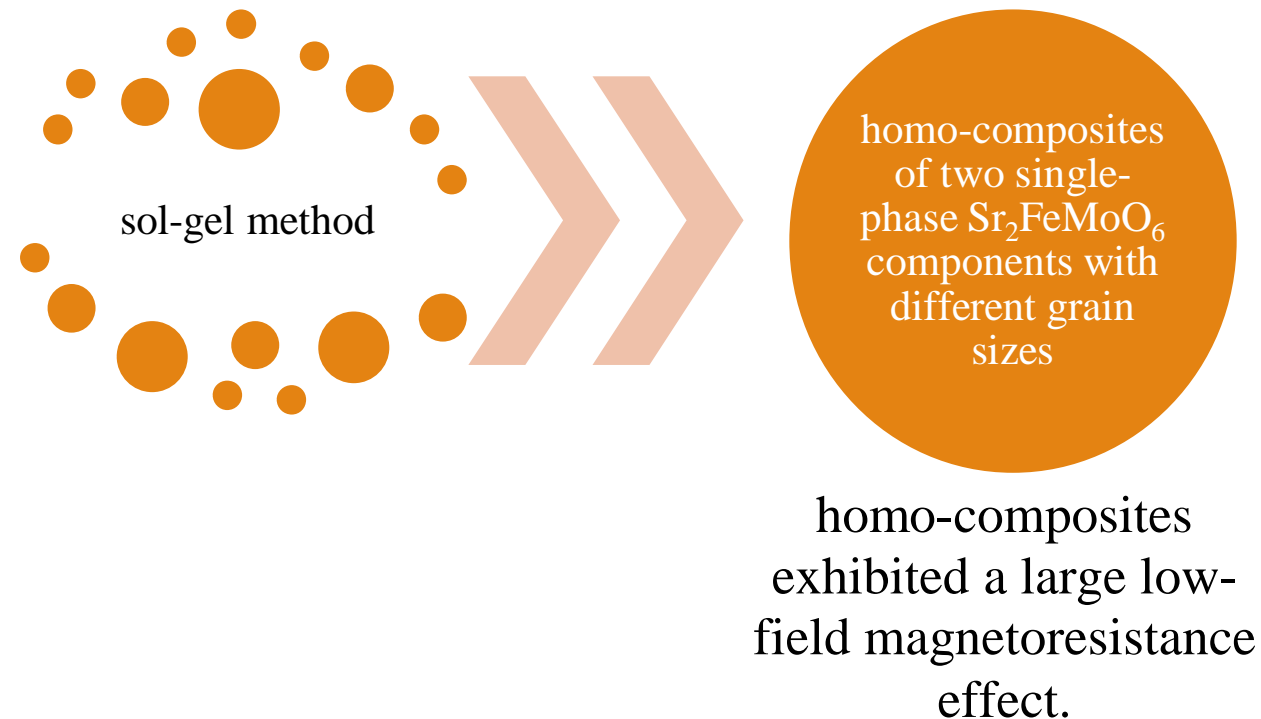
Large low-field magnetoresistance effect in $\text{Sr}_2\text{FeMoO}_6$ homocomposites

Y. H. Huang; J. Lindén; H. Yamauchi; ... et. al



Appl. Phys. Lett. 86, 072510 (2005)

<https://doi.org/10.1063/1.1864241>



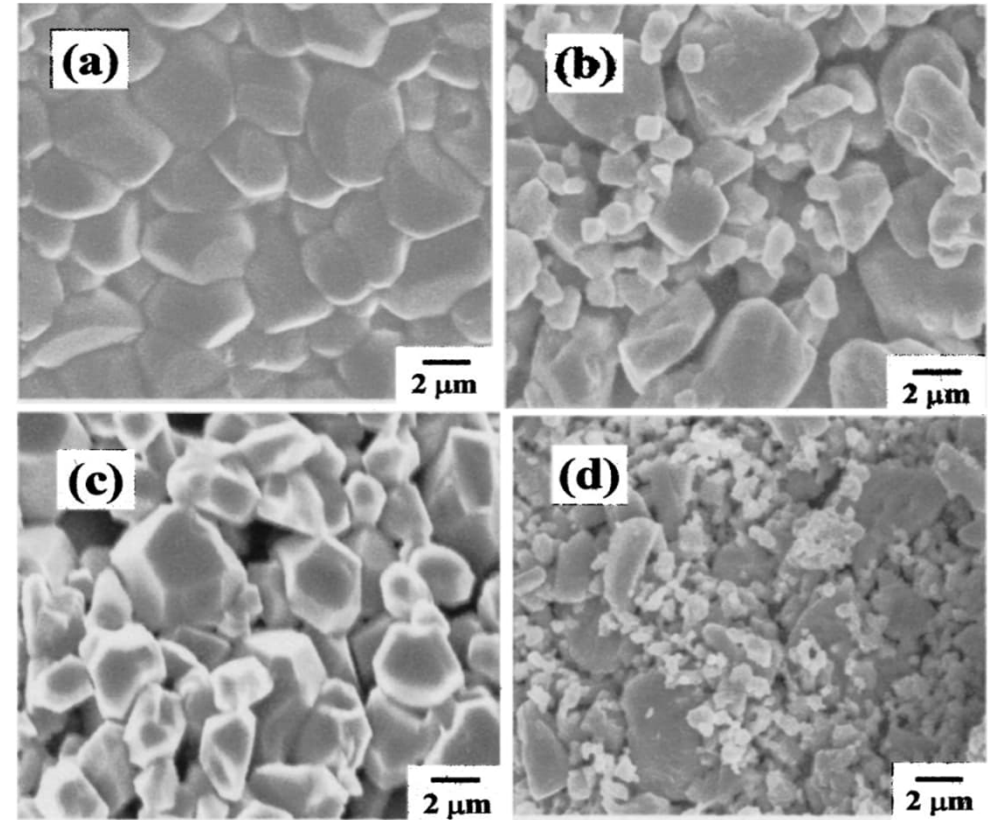
Characteristic methods:

- XRD → crystal structure and phase purity.
- SEM → morphology and microstructure of the samples.
- EDS → elemental composition
- Magnetization measurements → magnetic properties.
- Electrical transport measurements → magnetoresistance effect.

SEM images for $\text{Sr}_2\text{FeMoO}_6$ homo-composites

- ❑ Homogeneous morphology with two different grain sizes.
- ❑ The larger grains $\sim 3.8 \mu\text{m}$, while the smaller grains $\sim 1 \mu\text{m}$.
- ❑ Dense and uniform microstructure.
→ high magnetic and transport properties.

LFMR strongly depends on the relative amounts of the two components and their grain sizes.



SEM images for typical $\text{Sr}_2\text{FeMoO}_6$ homo-composites: a) $x=0$, b) $x=0.2$, $T_s=950 \text{ }^\circ\text{C}$, c) $x=0.2$, $T_s=1100 \text{ }^\circ\text{C}$, d) $x=0.5$, $T_s=950 \text{ }^\circ\text{C}$. [6]

Atomic Layer Deposition of Lithium Phosphorus Oxynitride

Mikko Nisula,[†] Yohei Shindo,[‡] Hideyuki Koga,[‡] and Maarit Karppinen^{*†}

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[‡]Higashifuji Technical Center, Toyota Motor Co., 1200 Mishuku, Susono, Japan

- ❑ Development of ALD process for producing high-quality LiPON thin films with a high N-to-P ratio → high ionic conductivity → coatings in 3D Li-ion micro-batteries.
- ❑ Use a novel N-containing P precursor + a lithium precursor → simultaneous incorporation of P and N in the films.

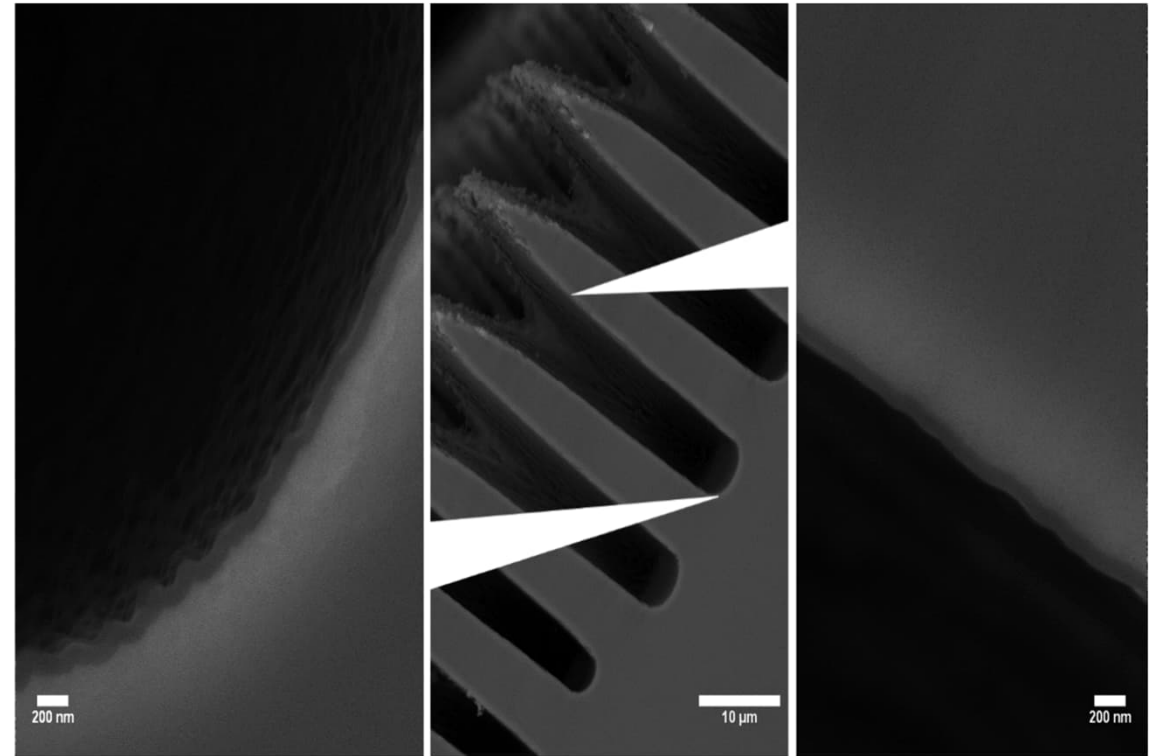
Characteristic methods :

- ❑ XPS → chemical composition of the thin films.
- ❑ Rutherford backscattering spectroscopy (RBS) and nuclear reaction analysis (NRA) → elemental composition/thickness of the thin films.
- ❑ FTIR → chemical bonding in the thin films.
- ❑ SEM → morphology and thickness of the thin films.
- ❑ Electrochemical impedance spectroscopy (EIS) → ionic conductivity of the thin films.

Cross-section SEM images of LiPON deposited on 3D-microstructured silicon.

The conformality of the LiPON ALD process was tested on a micron scale trench pattern $\sim 40\ \mu\text{m}$ deep and $\sim 5\ \mu\text{m}$ wide:

- ❑ Thin film is very uniform in thickness at the top and the bottom of the trench.
- ❑ Nanoscale roughness of the substrate is perfectly replicated.
- ❑ Excellent thickness obtained $\sim 80\ \text{nm}$



SEM images of LiPON deposited on 3D-microstructured silicon. [7]

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- [7] Mikko Nisula, Yohei Shindo, Hideyuki Koga, and Maarit Karppinen, Atomic Layer Deposition of Lithium Phosphorus Oxynitride, *Chemistry of Materials* 2015 27 (20), 6987-699, DOI: 10.1021/acs.chemmater.5b02199

Thank you